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Alex J. Rhim is a foreign attorney at Shin & Kim who focuses on intellectual property disputes with an emphasis on patent litigation. Alex also advises clients in technology and commercial transactions involving intellectual property.

工作经历

2024-Present	Shin & Kim LLC
2022-2024	Associate, Willkie Farr & Gallagher LLP, San Francisco
2020-2022	Associate, Paul Hastings LLP, Palo Alto
2019	Summer Associate, Paul Hastings LLP, Palo Alto

教育背景

2020	Georgetown University Law Center (J.D.)
2015	Georgia Institute of Technology (B.S., Electrical Engineering)

资格

2021	Admitted to bar, California
2017	Admitted to patent bar, U.S.A.

语言

Korean, English

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